LARATION FOR PATENT APPL TION

As a below named inventor(s), I (we) hereby declare that:							
My (our) residence(s), post office address(es) and citizenship(s) is (are) the same as stated below next to my (our) name(s).							
I (we) believe I am (we are) an original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled: SILICON WAFER, AND MANUFACTURING METHOD AND HEAT TREATMENT METHOD OF THE SAME							
the specification of which is att	tached hereto unless the following	ng box is checked:					
	the specification of which is attached hereto unless the following box is checked: [] was filed on as United States Application Number or						
	lication Number						
and was amended on	(if ap	plicable).	*				
	have reviewed and understand t ded by any amendment referred	he contents of the above identified to above.	ied specification,				
I (we) acknowledge the duty to Federal Regulations, §1.56.	disclose information which is m	naterial to patentability as define	ed in Title 37, Code of				
application(s) for patent or inve	entor's certificate listed below ar	ted States Code, §119(a)-(d) of nd have also identified below an of the application on which prior	y foreign application for				
	Prior Foreign Application(s):	· · · · · · · · · · · · · · · · · · ·					
(Number)	(Country)	· [
I (we) hereby claim the benefit under Title 35, United States Code, §119(e) of any United States provisional application(s) listed below:							
	(Application Number)	(Filing	Date)				
I (we) hereby claim the benefit under Title 35, United States Code, § 120 of any United States application(s) listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application in the manner provided by the first paragraph of Title 35, United States Code, § 112, I (we) acknowledge the duty to disclose information which is material to patentability as defined in Title 37, Code of Federal Regulation, §1.56 which became available between the filing date of the prior application and the national or PCT international filing date of this application.							
(Application Serial No.)	(Filing date)	(STATUS-patented,	pending, abandoned)				
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I (we) hereby appoint the following attorney(s) and/or agent(s) to prosecute this application and to transact all business in the Patent and Trademark Office connected therewith and to act in accordance with the instructions from Suda Patent Office:

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I (we) hereby declare that all statements made herein of my (our) own knowledge are true, and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

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CLARATION FOR PATENT APPLATIO

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